

Contact Information:

Angela Ausman  
Molecular Imprints, Inc.  
1-512-334-1203  
angela@molecularimprints.com

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**MOLECULAR IMPRINTS EXPANDS OPERATIONS INTO ASIA**

AUSTIN, TX, October 26, 2004 – Molecular Imprints, Inc. (MII), the leading manufacturer of Step and Flash Imprint Lithography (S-FIL™) equipment announced today that it has expanded its operations into Asia. Based in Tokyo, Japan, Molecular Imprints, Japan will offer technology and applications support for customers throughout the region. The office will also provide assistance to Hakuto Co., Ltd and to KLA-Tencor. Hakuto is MII's exclusive Asian distributor in the nanotechnologies-related market segments, while KLA-Tencor is MII's exclusive sales and services organization in the silicon-based markets for Asia and North America.

Molecular Imprints, Japan will be staffed by Mr. Hideyuki Wada. With over 12 years of semiconductor industry experience, Mr. Wada will be instrumental in helping customers realize the full potential of S-FIL technology and achieve optimum results when deploying MII's tools.

Norm Schumaker, MII's CEO, states, "The need for cost-effective, high resolution lithography continues to increase within the nanotechnology and silicon related markets in Asia. By expanding our operations to Japan, we look forward to supporting our rapidly-growing customer base in this key region."

**About Molecular Imprints Inc.**

Molecular Imprints, Inc.(MII) develops and manufactures nano-lithography systems for high resolution and for 3-dimensional pattern replication. The company has commercialized a unique Step and Flash Imprint Lithography technology (S-FIL), which is a simple step and repeat, room temperature, low pressure, nano-imprint process that has demonstrated sub-20 nanometer resolution.

Molecular Imprints provides enabling lithography systems and technology for manufacturing applications in the areas of: nano-devices, micro structures, advanced packaging, bio-devices, optical components and semiconducting devices. MII's Imprio™ product family is a cost-effective substitute for next generation lithography systems, at a fraction of the price. For more information, visit: [www.molecularimprints.com](http://www.molecularimprints.com).